501841430 03/05/2012

PATENT ASSIGNMENT

Electronic Version v1.1 Stylesheet Version v1.1

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT

CONVEYING PARTY DATA

Name	Execution Date
James R. Shealy	02/03/2012
Richard Brown	02/24/2012

RECEIVING PARTY DATA

Name:	Cornell University
Street Address:	395 Pine Tree Road
Internal Address:	Suite 310
City:	Ithaca
State/Country:	NEW YORK
Postal Code:	14850

PROPERTY NUMBERS Total: 1

Property Type	Number
Application Number:	13380144

CORRESPONDENCE DATA

 Fax Number:
 (607)330-4015

 Phone:
 607-330-4000

 Email:
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Correspondence will be sent to the e-mail address first; if that is unsuccessful, it will be sent via US

Mail.

Correspondent Name: BOND, SCHOENECK & KING, PLLC
Address Line 1: 10 BROWN ROAD, SUITE 102
Address Line 4: ITHACA, NEW YORK 14850-1248

ATTORNEY DOCKET NUMBER:	606P058A/591287

Total Attachments: 4

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> PATENT REEL: 027805 FRAME: 0001

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CHEMICAL VAPOR DEPOSITION PROCESS FOR ALUMINUM SILICON NITRIDE 606P058A CCTEC Ref. No. 4661-03-US

ASSIGNMENT

WHEREAS, We, James R. Shealy, a citizen of the United States of America, residing at 615 Wyckoff Road, Ithaca, NY 14850, and Richard Brown, a citizen of the United States of America, residing at 116 Schuyler Place, Ithaca, NY 14850, have invented certain new and useful improvements in CHEMICAL VAPOR DEPOSITION PROCESS FOR ALUMINUM SILICON NITRIDE for which an application for Letters Patent in the United States was filed as U.S. Serial No. 13/380,144 on December 22, 2011.

AND WHEREAS, Cornell University, with its principal place of business at Cornell Center for Technology, Enterprise & Commercialization ("CCTEC"), 395 Pine Tree Road, Suite 310, Ithaca, New York 14850 USA, is entitled to acquire the entire right, title and interest in and to the said improvements and the said Application:

NOW, THEREFORE, for good and valuable consideration, including salary or payment for the making of inventions, or employee benefits, the receipt of which is hereby acknowledged, we, the said inventors, do hereby acknowledge that we have sold, assigned, transferred and set over, and by these presents do hereby sell, assign, transfer and set over, unto the said Cornell University, its successors, legal representatives and assigns, the entire right, title and interest throughout the world in, to and under the said improvements, and the said application and all divisions, renewals, and continuations thereof, and all Letters Patent of the United States which may be granted thereon and all reissues and extensions thereof, and all rights of priority under International Conventions and applications for Letters Patent which may hereafter be filed for said improvements in any country or countries foreign to the United States, and all Letters Patent which may be granted for said improvements in any country or countries foreign to the United States and all extensions, renewals and reissues thereof; and we hereby authorize and request the Commissioner of Patents of the United States, and any Official of any country or countries foreign to the United States, whose duty it is to issue patents on applications as aforesaid, to issue all Letters Patent for said improvements to the said Cornell University, its successors, legal representatives and assigns, in accordance with the terms of this instrument.

AND WE HEREBY covenant and agree that we will communicate to the said Cornell University, its successors, legal representatives, and assigns, any facts known to us respecting said improvements and testify in any legal proceeding, sign all lawful papers, execute all divisional, continuing, and reissue applications, make all rightful oaths and generally do everything possible to aid the said Cornell University, its successors, legal representatives, and assigns, to obtain and enforce proper patent protection for said improvements in all countries.

PATENT

REEL: 027805 FRAME: 0002

CHEMICAL VAPOR DEPOSITION PROCESS FOR ALUMINUM SILICON NITRIDE 606P058A

CCTEC Ref. No. 4661-03-US

N TESTIMONY WHEREOF ary, 2012 (5	, I hereunto set my han Janue	nd this <u>3</u> day of R. Shew
	James R. Shea	ly
N TESTIMONY WHEREOF ary, 2012.	, I hereunto set my han	

PATENT REEL: 027805 FRAME: 0003

CHEMICAL VAPOR DEPOSITION PROCESS FOR ALUMINUM SILICON NITRIDE 606P058A

CCTEC Ref. No. 4661-03-US

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CHEMICAL VAPOR DEPOSITION PROCESS FOR ALUMINUM SILICON NITRIDE 606P058A CCTEC Ref. No. 4661-03-US

F	IN TESTIMONY WHEREOF, I hereunto set my hand this day of ebruary, 2012
	James R. Shealy
F	IN TESTIMONY WHEREOF, I hereunto set my hand this <u>24 th</u> day of ebruary, 2012.
	Dichard Brown

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PATENT REEL: 027805 FRAME: 0005